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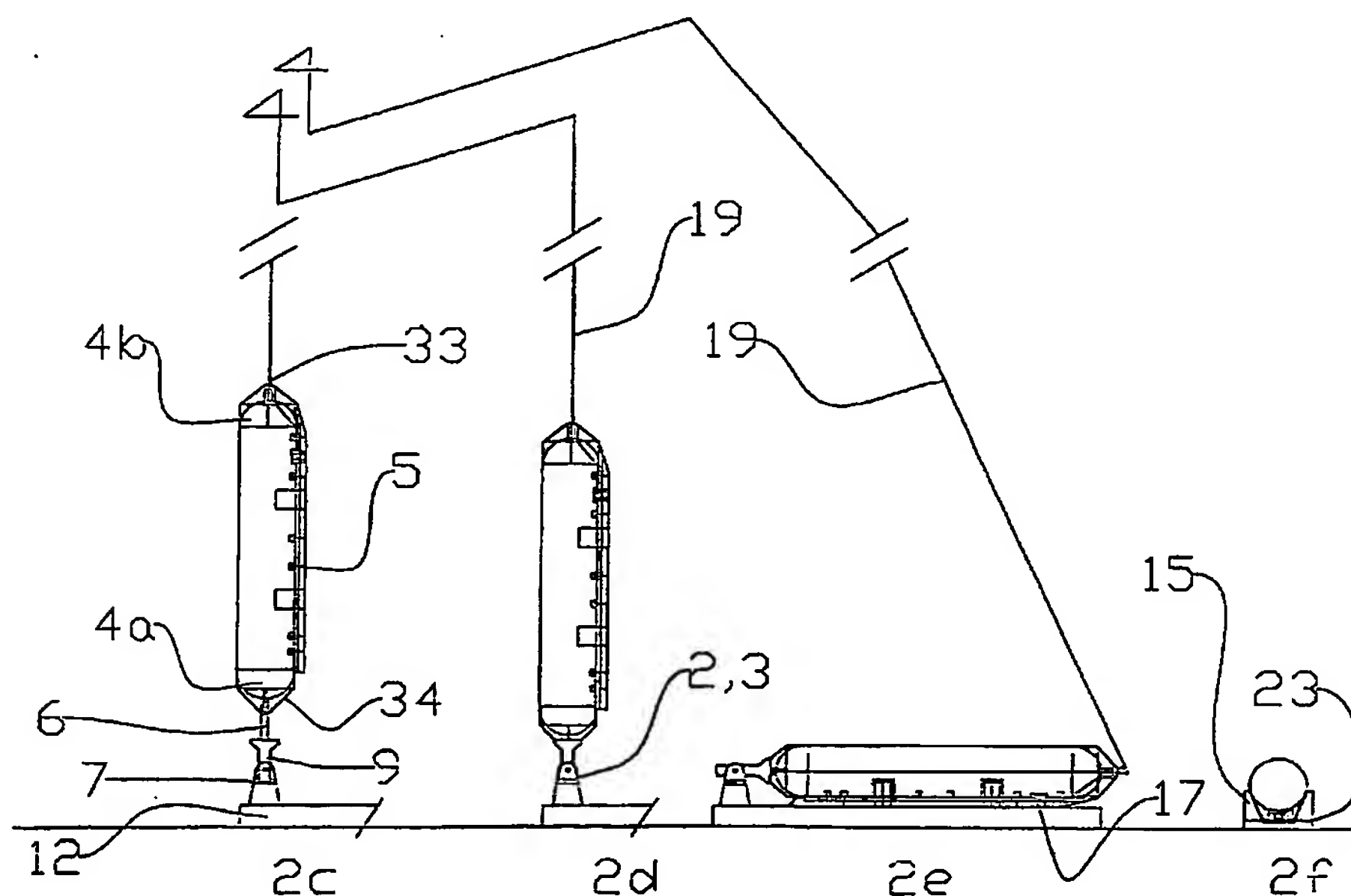
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(54) Title: VERTICAL INSTALLATION OF AN ELONGATED PROCESS UNIT



(57) Abstract: This invention relates to a method for installation of an elongate process unit (4) on the seabed, said process unit (4) to be handled comprising a first process unit end and a second process unit end. A method of retrieving an elongate process unit (4) from the seabed is also provided. Further, this invention relates to a receptor apparatus for use in a process unit handling operation, such as a process unit installation or retrieval operation.

**Declarations under Rule 4.17:**

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